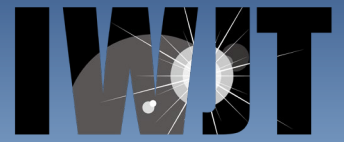


# CALL FOR PAPER



**IWJT2025, 25th Anniversary**

## 22nd International Workshop on Junction Technology

**June 5th–6th (Thu.–Fri.), 2025,  
Kyoto University, Uji Campus**

Conference Website

<https://smartconf.jp/content/iwjt2025/>



The IWJT, started in 2000 and was held annually in Japan or China, is an open forum focused on the needs and interests of the community on a junction formation technology in semiconductors. The workshop will provide a good opportunity for researchers and engineers to present their new research results, and exchange ideas with leading scientists.

**Deadline of full manuscript (2-4 pages) submission: April 22nd, 2025**

Best Paper Award and Young Award (under 35 age on the workshop day) will be selected.  
Detail can be seen in the conference website.

### Scopes of IWJT2025

- Power Devices
- Advanced CMOS
- Memory Devices
- Image Sensors

Process

Device

Design

- Annealing
- Doping (Epi. & Implantation)
- Advanced Equipment
- Engineered Substrates
- 3D Integration
- 2D Materials

- Characterization
- Modeling
- Simulation

### Committees

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